AMENDMENT UNDER 37 C.F.R. 1.116 - EXPEDITED PROCEDURE

Serial Number: 10/815,464 Filing Date: March 31, 2004

Title: METHOD OF EMBEDDING PASSIVE COMPONENT WITHIN VIA

Assignee: Intel Corporation

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IN THE CLAIMS

Please amend the claims as follows.

- 1. 31. (Canceled)
- 32. (Currently Amended) A method comprising:

forming a via in a substrate;

removing a portion of the via in the substrate to form a first via portion and a second via portion; and

forming an electrical component in the via in the substrate, wherein the electrical component includes at least a portion of memory.

- 33. (Previously Presented) The method of claim 32 wherein forming an electrical component in the via includes forming at least a portion of a resistor.
- 34. (Previously Presented) The method of claim 32 wherein forming an electrical component in the via includes forming at least a portion of a capacitor.
- 35. (Previously Presented) The method of claim 32 wherein forming an electrical component in the via includes forming at least a portion of a core.
- 36. (Previously Presented) The method of claim 32 wherein forming an electrical component in the via includes forming a resistor.
- 37. (Previously Presented) The method of claim 32 wherein forming an electrical component in the via includes forming a core.
- 38. (Canceled)

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39. (Previously Presented) The method of claim 32 wherein forming an electrical component in the via includes forming a memory.

- 40. (Previously Presented) The method of claim 32 wherein the electrical component in the via includes a passive electrical component.
- 41. (Previously Presented) The method of claim 32 wherein the electrical component in the via is a passive electrical component.
- 42. (Previously Presented) The method of claim 32 wherein the electrical component includes a capacitor further comprising:

an inner cylindrical portion; and an outer via portion substantially surrounding the inner cylindrical portion.

- 43. (Previously Presented) The method of claim 32 wherein the electrical component includes a capacitor further comprising:
 - a first curved portion; and
- a second curved portion spaced from the first curved portion, wherein the distance between the first curved portion and the second curved portion vary.
- 44. (Previously Presented) The method of claim 32 wherein the electrical component includes a capacitor further comprising:
 - a first curved portion; and
- a second curved portion spaced from the first curved portion, wherein the first curved portion and the second curved portion are portions of a via formed by insulating a first portion of a via from a second portion of a via.
- 45. (Previously Presented) A method comprising:

forming a via in a substrate; and

forming at least a portion of a transformer within the via.

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46. - 68. (Canceled)

69. (Previously Presented) A method comprising:

forming a via in a substrate; and

forming a capacitor in the via in the substrate, wherein forming the capacitor further comprises:

forming a first curved plate portion; and

forming a second curved plate portion spaced from the first curved plate portion, wherein the distance between the first curved plate portion and the second curved plate portion vary.

70. (Previously Presented) A method comprising:

forming a via in a substrate; and

forming a capacitor in the via in the substrate, wherein forming the capacitor further comprises:

forming a first curved plate portion; and

forming a second curved plate portion spaced from the first curved plate portion, wherein the first curved plate portion and the second curved plate portion are portions of a via formed by insulating the first portion of a via from a second portion of a via.

71. (Canceled)

72. (New) The method of claim 32 wherein forming an electrical component in the via further includes:

forming a first electrical component from the first via portion; and forming a second electrical component from the second via portion.

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73. (New) The method of claim 32 wherein removing a portion of the via in the substrate to form a first via portion and a second via portion further includes:

masking a portion of the via; and

etching an unmasked portion of the via.